

Chapter 5: Diffusion (1)

Diffusion - Mass transport by random, atomic (or molecular-scale) motion

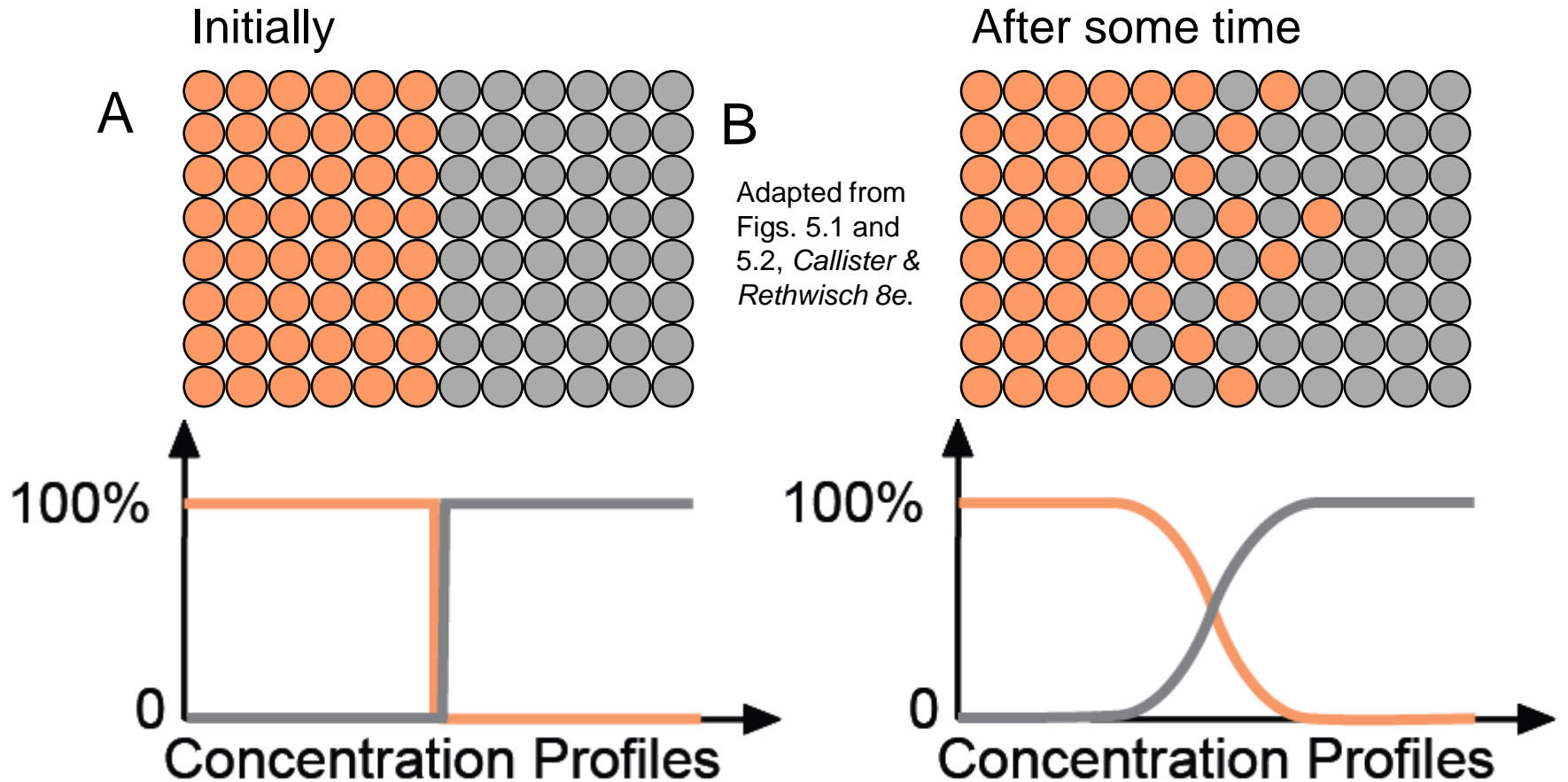
ISSUES TO ADDRESS...

- How does diffusion occur?
- Why is it an important part of processing?
- How can the rate of diffusion be predicted for some simple cases?
- How does diffusion depend on structure and temperature?



Diffusion

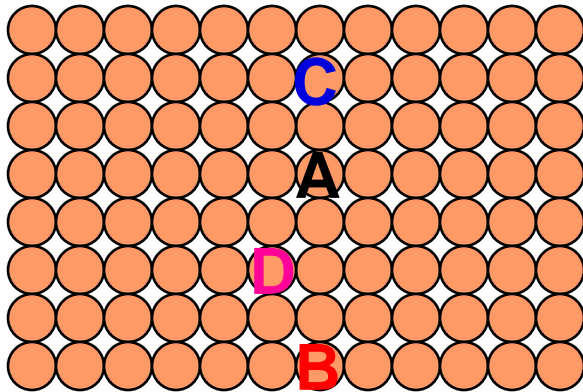
- **Interdiffusion:** when joining different metals (or in other materials system), atoms (or other species) tend to migrate from regions of high conc. to regions of low conc.



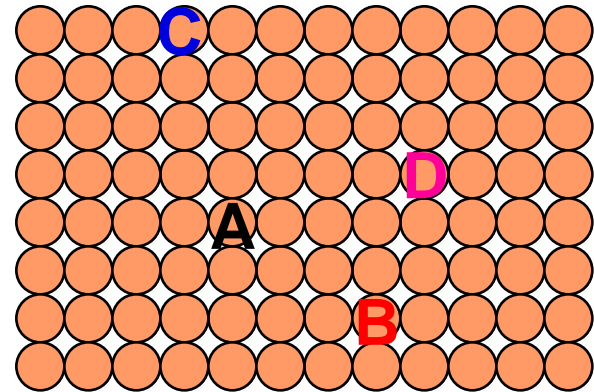
Diffusion

- **Self-diffusion:** Even in an pure elemental solid, atoms also migrate randomly via self-diffusion process.

Label some atoms



After some time



Examples of (Inhibiting) Diffusion

- Different packaging for food to preserve freshness, e.g.,

- CO₂ diffuses out from bottles
- O₂ diffuses into the bottles



- Paints applied to metal surface to prevent corrosion

- O₂, H₂O, and salt diffuse through the paint layer (even undamaged) to corrode metals underneath



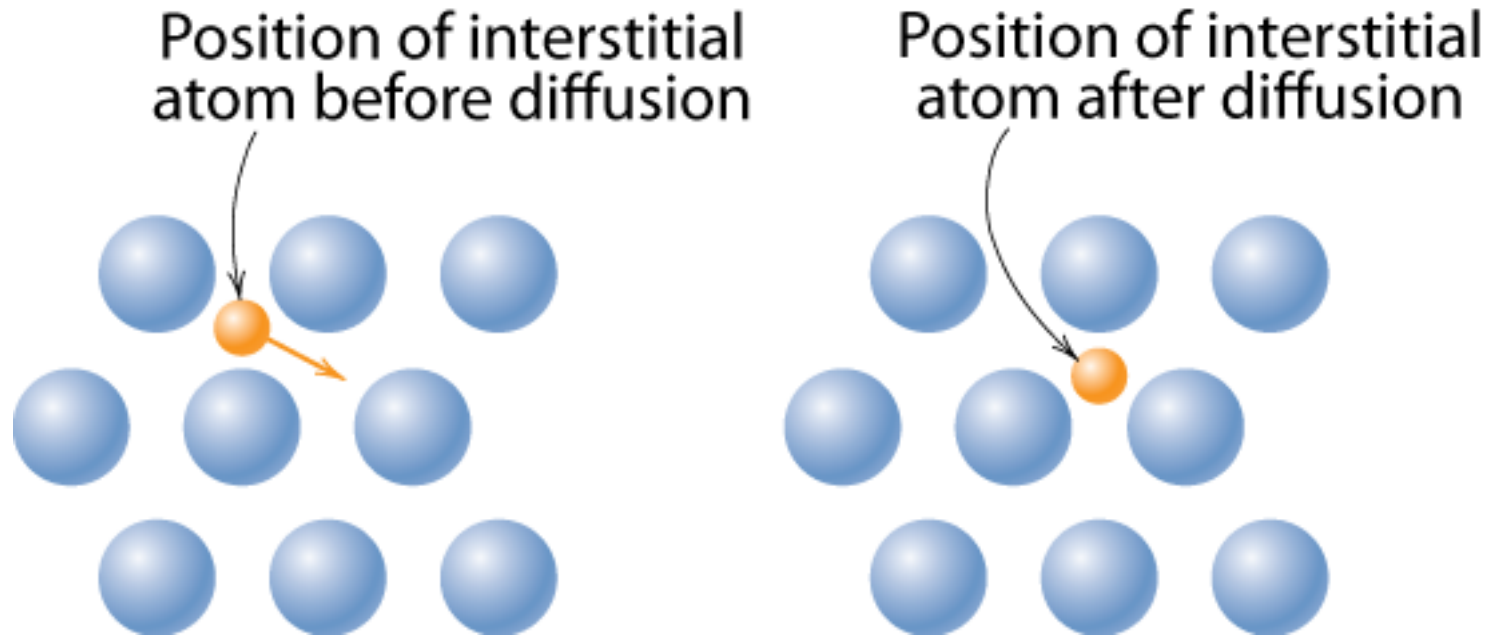
<http://www.core77.com/posts/38703/Disguising-Your-Car-with-Fake-Rust-Looks-Interesting-But-Wont-Prevent-Someone-From-Stealing-It>



Diffusion Mechanisms (1)

Interstitial diffusion

Smaller atoms/molecules can diffuse through the interstitial sites between larger atoms/molecules.



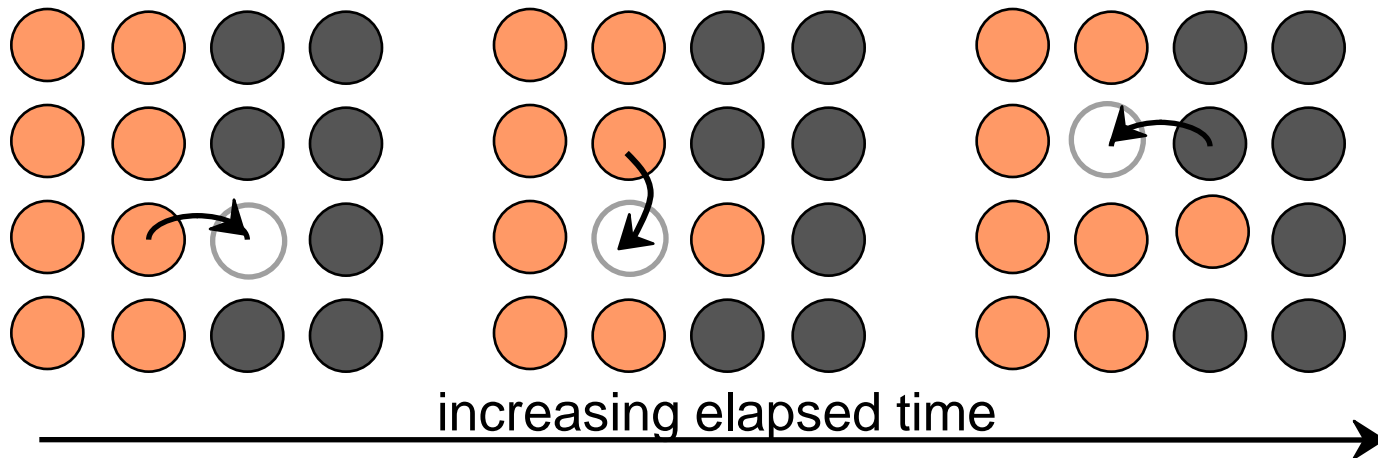
Adapted from Fig. 5.3(b), *Callister & Rethwisch 8e*.

Diffusion Mechanisms (2)

Substitutional Diffusion via vacancy exchange

For pure elements or alloys with similar sized atoms (e.g., Ni-Cu)

- atoms exchange with vacancies
- applies to substitutional impurities atoms and also self diffusion
- rate depends on:
 - vacancies concentration
 - activation energy to exchange.



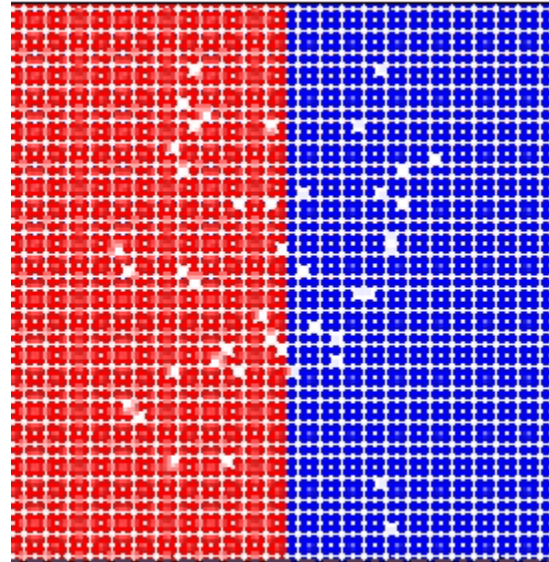
Substitutional diffusion via exchange with vacancy usually much slower than interstitial diffusion



Simulation of Vacancy Diffusion

- Simulation of interdiffusion across an interface:
- Rate of substitutional diffusion depends on:
 - vacancy concentration
 - frequency of jumping.

This slide contains an animation that requires Quicktime and a Cinepak decompressor. Click on the message or image below to activate the animation.



(Courtesy P.M. Anderson)



Materials Processing Using Diffusion (1)

Example of **Case Hardening** :

The surface of a metal gear needs to be hard (for wear resistance) while the inside needs to be tough (not brittle)

Approach:

- Diffuse carbon (atoms) into the surface of the steel (iron) gear via heat treatment in a carbon-rich atmosphere
- Carbon atoms are much smaller than Fe atoms – interstitial diffusion mechanism



Adapted from chapter-opening photograph, Chapter 5, *Callister & Rethwisch 8e.* (Courtesy of Surface Division, Midland-Ross.)

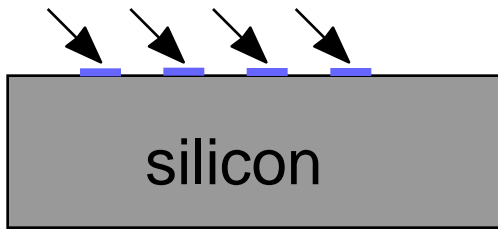
Result: The presence of C atoms in the surface makes the surface of steel (iron) harder and wear resistant while inside remains low in carbon content and tough (not brittle)



Materials Processing Using Diffusion (2)

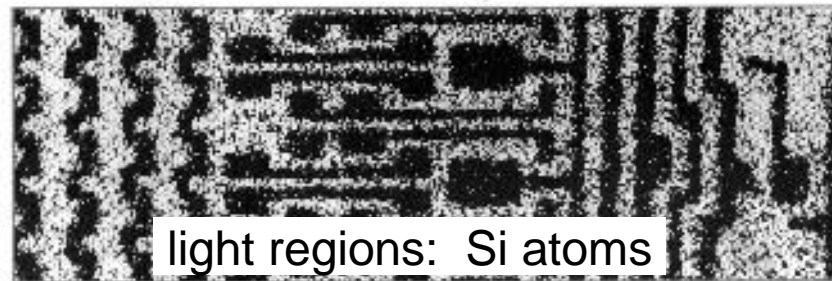
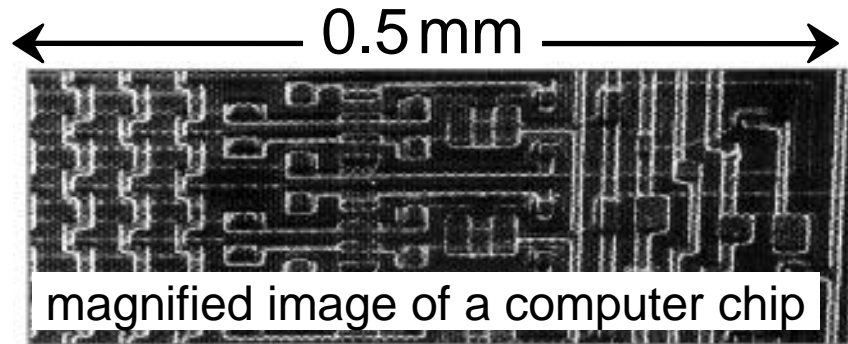
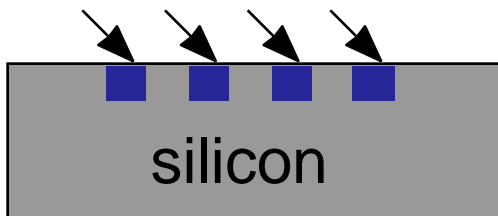
- **Doping** silicon with phosphorus for *n*-type semiconductors:
- Process:

1. Deposit **P** rich layers on surface.



2. Heat it.

3. Result: Doped semiconductor regions for functional micro-chips



Adapted from Figure 18.27, *Callister & Rethwisch 8e.*



Diffusional Flux

- How do we quantify the amount or rate of diffusion?

$$J \equiv \text{Flux} \equiv \frac{\text{moles (or mass) diffusing}}{(\text{cross - section area})(\text{time})} = \frac{\text{mol}}{\text{cm}^2\text{s}} \text{ or } \frac{\text{kg}}{\text{m}^2\text{s}}$$

$$J = \frac{1}{A} \frac{dM}{dt}$$

Fick's 1st Law about Diffusion

Fick's first law of diffusion for 1D: Flux

$$J = -D \frac{dC}{dx}$$

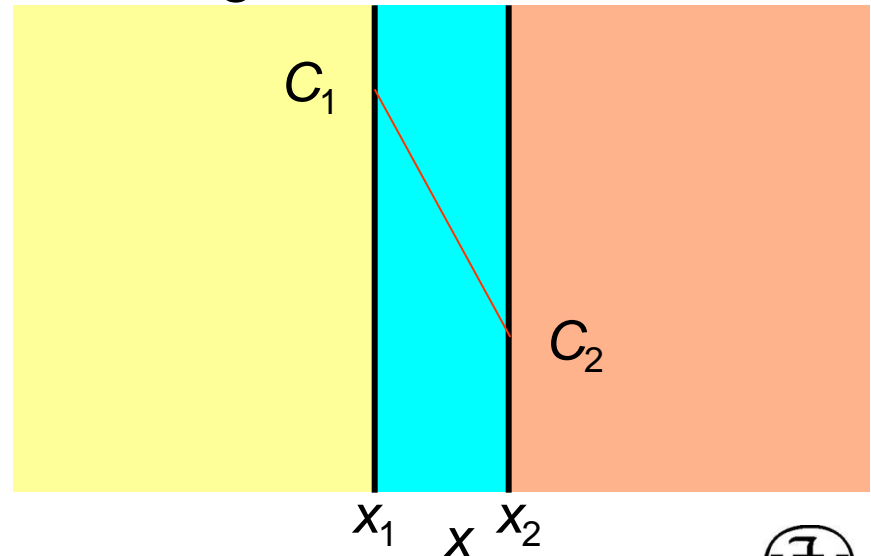
$D \equiv$ **diffusion coefficient**, in unit of **cm²/sec** or similar

$C \equiv$ **concentration**, in unit of **mole/cm³** or similar

$x \equiv$ **distance**, in unit of **cm** or similar

dC/dx **concentration gradient** along x direction

$$\text{if linear } \frac{dC}{dx} \cong \frac{\Delta C}{\Delta x} = \frac{C_2 - C_1}{x_2 - x_1}$$



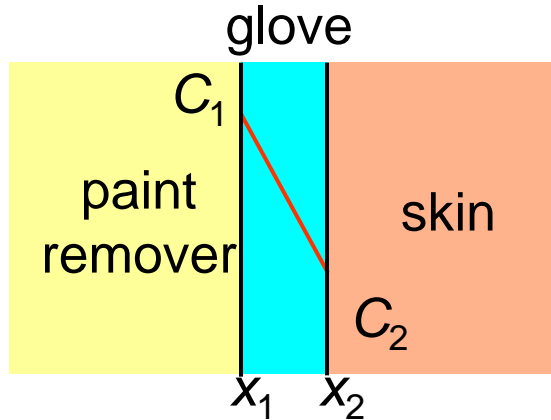
Other Example: Chemical Protective Clothing (CPC)

- Methylene chloride is a common ingredient of paint removers. Besides being an irritant, it also may be absorbed through skin. When using this paint remover, protective gloves should be worn.
- If butyl rubber gloves (0.04 cm thick) are used, what is the **diffusive flux** of methylene chloride through the glove if assuming linear concentration distribution?
- Given:
 - diffusion coefficient in butyl rubber:
 $D = 110 \times 10^{-8} \text{ cm}^2/\text{s}$
 - surface concentrations:
 C_1 (outside glove) = 0.44 g/cm³
 C_2 (inside glove) = 0.02 g/cm³



Example: Chemical Protective Clothing (CPC) (cont).

- **Solution** –linear conc. gradient



$$J = -D \frac{dC}{dx} \cong -D \frac{C_2 - C_1}{x_2 - x_1}$$

Data: $D = 110 \times 10^{-8} \text{ cm}^2/\text{s}$

$C_1 = 0.44 \text{ g/cm}^3$

$C_2 = 0.02 \text{ g/cm}^3$

$x_2 - x_1 = 0.04 \text{ cm}$ (thickness of glove)

$$J = -(110 \times 10^{-8} \text{ cm}^2/\text{s}) \frac{(0.02 \text{ g/cm}^3 - 0.44 \text{ g/cm}^3)}{(0.04 \text{ cm})} = 1.16 \times 10^{-5} \frac{\text{g}}{\text{cm}^2\text{s}}$$



Diffusion Coefficient and Temperature (1)

- Diffusion coefficient increases “exponentially” with increasing temperature T .

$$D = D_o \exp\left(-\frac{Q_d}{RT}\right)$$

D = diffusion coefficient [m^2/s]

D_o = pre-exponential [m^2/s]

Q_d = activation energy [J/mol]

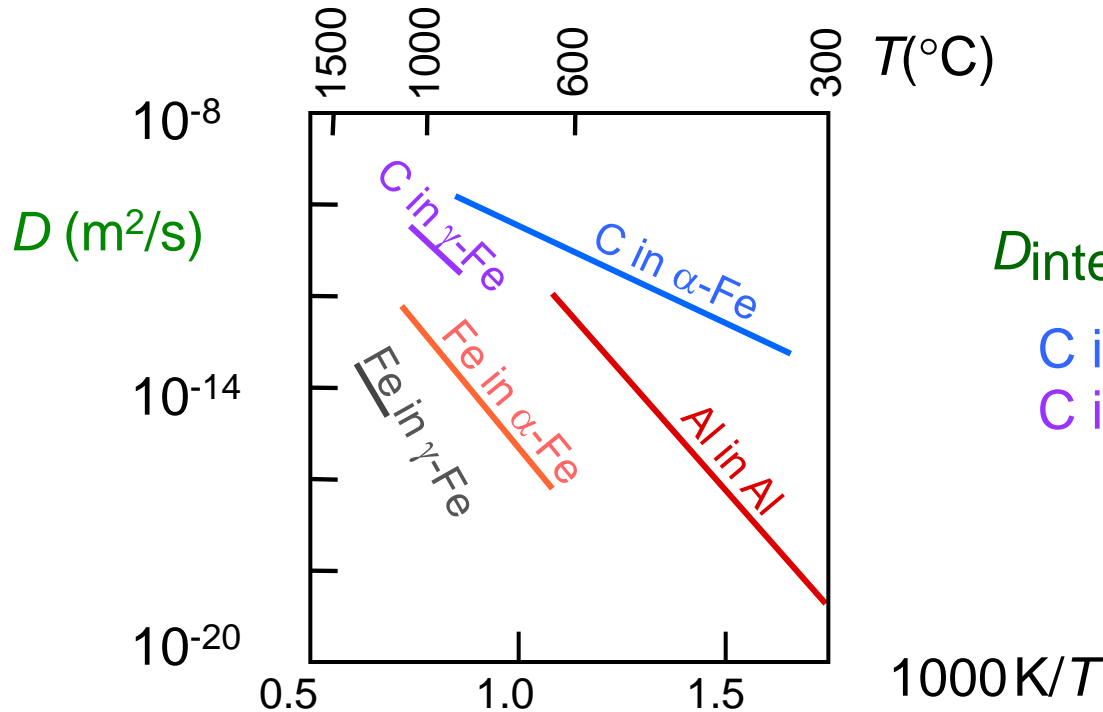
R = gas constant [$8.314 \text{ J}/\text{mol}\cdot\text{K}$]

T = absolute temperature [K]



Diffusion Coefficient and Temperature (2)

D has “exponential” dependence on T : higher $T \rightarrow$ much higher D



$D_{\text{interstitial}} \gg D_{\text{substitutional}}$

$\text{C in } \alpha\text{-Fe}$
 $\text{C in } \gamma\text{-Fe}$

Al in Al
 $\text{Fe in } \alpha\text{-Fe}$
 $\text{Fe in } \gamma\text{-Fe}$

Adapted from Fig. 5.7, Callister & Rethwisch 8e. (Date for Fig. 5.7 taken from E.A. Brandes and G.B. Brook (Ed.) *Smithells Metals Reference Book*, 7th ed., Butterworth-Heinemann, Oxford, 1992.)



Example: At 300°C the diffusion coefficient and activation energy for Cu in Si are

$$D_1(300^\circ\text{C}) = 7.8 \times 10^{-11} \text{ m}^2/\text{s}$$

$$Q_d = 41.5 \times 10^3 \text{ J/mol}$$

What is the diffusion coefficient at 350°C?

Solution

$$D = D_0 \exp\left(-\frac{Q_d}{RT}\right)$$

Knowing

$$D_1 = D_0 \exp\left(-\frac{Q_d}{RT_1}\right)$$

Wanting to know

$$D_2 = D_0 \exp\left(-\frac{Q_d}{RT_2}\right)$$



Example (cont.)

$$\frac{D_2}{D_1} = \frac{\exp\left(-\frac{Q_d}{RT_2}\right)}{\exp\left(-\frac{Q_d}{RT_1}\right)} \quad D_2 = D_1 \exp\left[-\frac{Q_d}{R} \left(\frac{1}{T_2} - \frac{1}{T_1}\right)\right]$$

$$T_1 = 273 + 300 = 573 \text{ K}$$

$$T_2 = 273 + 350 = 623 \text{ K}$$

$$D_2 = (7.8 \times 10^{-11} \text{ m}^2/\text{s}) \exp\left[\frac{-41,500 \text{ J/mol}}{8.314 \text{ J/mol-K}} \left(\frac{1}{623 \text{ K}} - \frac{1}{573 \text{ K}}\right)\right]$$

$$D_2 = 15.7 \times 10^{-11} \text{ m}^2/\text{s}$$



Summary

Diffusion is mass transport by random walking
Of atoms/molecules

Mechanism of diffusion include interstitial diffusion
mechanism and vacancy diffusion mechanism

For 1D, Fick's 1st Law gives $J = -D \frac{dC}{dx}$ that relates

diffusion flux J and concentration gradient dC/dx via a
material/system property of diffusion coefficient D

Diffusion coefficient D increases “exponentially” with
temperature T following

$$D = D_0 \exp\left(-\frac{Q_d}{RT}\right)$$

